

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :

Ji-Soo KIM et al. :

Serial No. [NEW] :

Filed: January 30, 2004 :

For: METHOD OF AND APPARATUS FOR MANUFACTURING A  
SEMICONDUCTOR DEVICE USING A POLYSILICON HARD MASK

**PRELIMINARY AMENDMENT**

U.S. Patent and Trademark Office  
2011 South Clark Place  
Customer Window, Mail Stop Patent Application  
Crystal Plaza Two, Lobby, Room 1B03  
Arlington, VA 22202

Sir:

Preliminary to the examination of the above-identified application, please enter  
the following amendments and consider the following remarks:

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of claims which begins  
on page 3 of this paper.

**Remarks/Arguments** begin on page 5 of this paper.